Electronic supplementary information for

Lattice Strain Controlled Ni@NiCu Efficient Anode Catalysts for Direct Borohydride Fuel Cell

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Fig. S1 Schematic diagram of the preparation catalysts.



Fig. S2 (a) The SEM images and (b) the enlarged view of the Ni catalyst; (c) the SEM images and (d) the enlarge view of the Ni catalyst after oxidation (Ni-ox).



Fig. S3 (a) The SEM image of Ni@NiCu and (b-d) corresponding EDS element distribution mappings.



Fig. S4 (a-d) Processed lattice fringe images of boxes 1, 2, 3 and 4 in Fig. 2(a), respectively.



Fig. S5 SEM-EDS patterns of (a) Ni@Ni-10, (b)Ni@Ni-20, (c)Ni@Ni-30. (d) The correlation curves between the Cu^{2+} concentration in deposition solution and the contents of Ni and Cu in the Ni@NiCu-x catalysts.



Fig. S6 (a) XPS surveys, (b) spectrums of Ni 2p_{3/2}, and (c) Cu 2p_{3/2} of Ni and Ni@NiCu catalysts.

The effect of tensile lattice stain on the electronic structure of Ni surface is evaluated by X-ray photoelectron spectroscopy (XPS), shown in Fig. S6. The peaks near 853 eV and 858.5 eV are corresponded to the metallic Ni (Ni⁰) and its satellite peaks,¹ while the peaks near 856.5 eV and 862 eV are attributed to Ni²⁺ and its satellite peaks.² Moreover, the Cu⁰ and Cu²⁺ peaks in Ni@NiCu are located around 932.6 eV and 935.1 eV, respectively.



Fig. S7 CV curves on (a) Ni, (b) Ni@NiCu-0, (c) Ni@NiCu-5, (d) Ni@NiCu-10, (e) Ni@NiCu-20, (f) Ni@NiCu-30 catalysts in 1 mol L⁻¹ NaOH solution at various scan rates, and (g) CV curve on Pt/C in 0.1 M HClO₄ at a scan rate of 50 mV s⁻¹. ECSA of Pt/C was calculated from a hydrogen adsorption peak from CV based on the equation: ECSA = $Q_{\rm H}$ / (210 µC cm⁻²), where $Q_{\rm H}$ is the charge of hydrogen electro-adsorption calculated from the shaded area.



Fig. S8 The $v \sim \Delta j$ relationship curves on different catalysts.



Fig. S9 The Tafel curves of BOR on Ni@NiCu-x, Ni, and commercial Pt/C catalysts in mixed a solution of 0.15 M NaBH₄ and 2 M NaOH at 25 $^{\circ}$ C.



Fig. S10 The EIS of BOR on Ni@NiCu-x, Ni, and commercial Pt/C catalysts in 0.15 M NaBH₄ and 2 M NaOH mixed solution at 25 °C. The inset is the equivalent circuit.



Fig. S11 The CV curves of BOR on (d) Ni and (e) Ni@NiCu-20 catalysts at different temperatures in a mixed solution of 0.15 M NaBH₄ and 2 M NaOH at a scan rate of 10 mV s⁻¹.



Fig. S12 The Tafel curves of HER on Ni@NiCu-x and Ni catalysts in 2 M NaOH solution at 25 °C.



Fig. S13 SEM images of Ni@NiCu-20 after discharge.



Fig. S14 CV curves of BOR on (a) Ni, (b) Ni@NiCu-0, (c) Ni@NiCu-5, (d) Ni@NiCu-10, (e) Ni@NiCu-20, and (f) Ni@NiCu-30 catalyst electrodes at various rotate speeds; Koutecky-Levich plots of BOR on Ni@NiCu-x and Ni catalyst electrodes at (g) 0.10 V, (h) 0.20 V, and (i) 0.25 V vs. RHE.



Fig. S15 Surface structure of (a) Ni-0% and (b) Ni@NiCu-2%, the grey and orange denote Ni and Cu atoms, respectively.



Fig. S16 Reaction pathway of BOR on Ni@NiCu-2% and Ni-0% at 0 V vs. RHE.



Fig. S17 Optimized structures of corresponding reaction intermediates in BOR on the Ni@NiCu-2% surface, the Ni, B, O and H atoms are denoted by gray, blue, red, and white balls, respectively.



Fig. S18 Optimized structures of corresponding reaction intermediates in BOR on the Ni-0% surface, the Ni, B, O and H atoms are denoted by gray, blue, red, and white balls, respectively.



Fig. S19 Projected DOS of the Ni@NiCu-2%.



Fig. S20 Optimized structures of corresponding reaction intermediates in BOR on the Ni-0%, Ni@NiCu-0%-x, and Ni@NiCu-2% surface, the Ni, B, O and H atoms are denoted by gray, blue, red, and white balls, respectively.



Fig. S21 Energy barrier for the fourth decoupling of B-H bond on Ni-0%, Ni@NiCu-0%-x, and Ni@NiCu-2% at 0.3 V vs. RHE.



Fig. S22 Comparison of the density of state of 3d orbitals of Ni-0%, Ni@NiCu-0%-x, and Ni@NiCu-2%.



Fig. S23 Configuration schematic diagram of DBFC unit.





Fig. S25 Practical application of the DBFC with the Ni@NiCu anode.

Catalyst	lattice parameter (Å)	^E micro (%)	SA- ^E micro (%)
Ni	3.522253	0.058321	0.00269
Ni@NiCu-0	3.523355	0.011008	0.0004
Ni@NiCu-10	3.524195	0.203011	0.016424
Ni@NiCu-20	3.524439	0.062177	0.005174
Ni@NiCu-30	3.5244392	0.021008	0.00062

Table S1 XRD refinement results of prepared catalysts.

Table S2 Summaries of electrocatalytic activities of prepared catalysts towards BOR.

Catalyst	<i>j</i> @0.3 V	Tafel slope	R _{ct}	$C_{ m dl}$
	(mA cm ⁻²)	(mV dec ⁻¹)	(Ω)	(mF)
Ni	132	317	6.10	7.22
Pt/C	69	325	5.48	-
Ni@NiCu-0	135	275	3.51	9.52
Ni@NiCu-5	177	267	2.61	8.89
Ni@NiCu-10	219	240	1.68	7.98
Ni@NiCu-20	246	163	1.08	8.41
Ni@NiCu-30	198	211	2.15	7.27

Table S3 The catalytic activities to BOR (at ~ 0.3 V vs. RHE) achieved by some typical noblemetal-based and Ni-based catalysts developed in recent years.

		$j_{\rm ECSA}$	
Catalyst	Testing condition	$(^{\text{mA cm}_{Cat.}^{-2}})$	Reference
Ni@NiCu-20	0.15 M NaBH ₄ + 2 M NaOH	6.57	This work
PdNi/C	0.05 M NaBH ₄ + 1 M KOH	0.45	3
Pd/C	0.05 M NaBH ₄ + 1 M KOH	0.15	3
Co-Ni-B	0.1 M KBH ₄ + 1 M KOH	0.55	4
Ni _{ED} /eNFT	$0.05 \text{ M NaBH}_4 + 1 \text{ M NaOH}$	0.13	5
Ni-np@NC	$0.135 \text{ M NaBH}_4 + 2 \text{ M NaOH}$	2.14	6
Ni@Zn	0.135 M NaBH ₄ + 2 M NaOH	1.8	7
Pt ₆₇ Fe ₃₃ /C	0.1 M NaBH ₄ + 3 M NaOH	1.64	8
Cu ₅₁ Ni ₃₇ Pd ₁₂ @Ni foam	0.3 M NaBH ₄ + 2 M NaOH	0.15	9

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